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				Application Number	TBD
				Filing Date	Herewith
				First Named Inventor	William W. Dostalick
				Group Art Unit	2814
				Examiner Name	Howard Weiss
Sheet	1	of	1	Attorney Docket No.	TI-34962.1

U.S. PATENT DOCUMENTS						
Exam. Initials*	Cite No. <sup>1</sup>	U.S. Patent Document		Name of Patentee or Applicant of Cited Doc.	Date of Pub. of Cited Doc. (mm-dd-yyyy)	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number	Kind Code <sup>2</sup> (if known)			
	AA	6,319,809		Chang et al.	11/20/01	
	AB	6,372,647		Lu et al.	4/16/02	
	AC					
	AD					
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FOREIGN PATENT DOCUMENTS								
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		Office <sup>3</sup>	Number <sup>4</sup>	Kind Code <sup>2</sup> (if known)				
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OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS			
Exam. Initials*	Cite No. <sup>1</sup>	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T <sup>2</sup>
	CA	U.S. Patent Application Publication No. 2002/0081855, June 27, 200, Jiang et al.	
	CB	S. SATYANARAYANA ET AL., "A Solution to Resist Poisoning in the Integration of 248 and 193 nm Photoresist with Low-k Dielectric Materials" Society of Photo-Optical Instrumentation Engineers, Santa Clara, California, March 2002	
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